# Electronic and magnetic properties of single chalcogen vacancies in MoS<sub>2</sub>/Au(111)

Sergey Trishin<sup>®</sup>, Christian Lotze<sup>®</sup>, Nils Krane, 1,2 and Katharina J. Franke<sup>®</sup>1 <sup>1</sup>Fachbereich Physik, Freie Universität Berlin, 14195 Berlin, Germany <sup>2</sup>nanotech@surfaces Laboratory, Empa - Swiss Federal Laboratories for Materials Science and Technology, Dübendorf, Switzerland

(Received 8 August 2023; accepted 4 October 2023; published 18 October 2023)

Two-dimensional (2D) transition-metal dichalcogenides (TMDCs) are considered highly promising platforms for next-generation optoelectronic devices. Owing to its atomically thin structure, device performance is strongly impacted by a minute amount of defects. Although defects are usually considered to be disturbing, defect engineering has become an important strategy to control and design new properties of 2D materials. Here, we produce single S vacancies in a monolayer of MoS<sub>2</sub> on Au(111). Using a combination of scanning tunneling and atomic force microscopy, we show that these defects are negatively charged and give rise to a Kondo resonance, revealing the presence of an unpaired electron spin exchange coupled to the metal substrate. The strength of the exchange coupling depends on the density of states at the Fermi level, which is modulated by the moiré structure of the MoS<sub>2</sub> lattice and the Au(111) substrate. In the absence of direct hybridization of MoS<sub>2</sub> with the metal substrate, the S vacancy remains charge neutral. Our results suggest that defect engineering may be used to induce and tune magnetic properties of otherwise nonmagnetic materials.

## DOI: 10.1103/PhysRevB.108.165414

#### I. INTRODUCTION

Monolayers of semiconducting transition-metal dichalcogenides (TMDCs) and related two-dimensional (2D) materials have recently attracted a lot of attention due to their intriguing optoelectronic properties [1]. The immense progress in flexible design of heterostructures has enabled the realization of device structures with unprecedented potential for efficient optoelectronic components [1,2]. However, device performance and reliability remain still to be improved. Due to the 2D nature, already a minute amount of defects has an immense influence on the properties of the material. As material growth and processing usually come along with a variety of defects, it is of utmost importance to understand their effects [3,4]. Most defects create states within the semiconducting band gap, and thus strongly modify the conductance and photoluminescence properties [5-15], but also affect the chemical reactivity [16].

The most prevalent structural defects in TMDCs are chalcogen vacancies owing to their low formation energy [7,17–21]. Similar to many defects, they introduce states in the pristine band gap, with their occupation, i.e., their charge state, being strongly influenced by the electrostatic environment [6,13,21-23]. Consequently, by adjusting the chemical potential of the monolayer's support, one can effectively control the charge state of the defects. When the defect state is singly occupied, the localized charge is accompanied by a local spin density. As a result, the TMDC material may exhibit paramagnetic or ferromagnetic behavior at high defect densities [24]. At very large defect densities or grain boundaries, the states may even interact and lead to the emergence of correlated states [25–27].

Here, we chose to investigate chalcogen vacancies in a monolayer of molybdenum disulfide (MoS<sub>2</sub>), which is in contact to a Au(111) substrate. MoS<sub>2</sub> belongs to the class of semiconducting TMDCs with an indirect band gap in the bulk, which evolves into a direct band gap in the single layer [28,29]. The intact monolayer is inert, as all Mo and S bonds are fully saturated, albeit with a strong interface hybridization at the Au-S interface [20,30]. The most abundant point defects in this system are S vacancies at the interface to the Au substrate [20]. To systematically study S vacancies in the top layer, we deliberately bombard the sample with Ne ions. We show that these defects are charged and host a localized electron spin which is manifested in a Kondo resonance. When the MoS<sub>2</sub> layer is not directly hybridized with the Au(111) substrate, there is no Kondo resonance, and the states inside the semiconducting band gap are similar to those expected for S vacancies on freestanding MoS<sub>2</sub>. Our results thus highlight the role of a metal support for controlling the charge state and magnetic properties.

## II. EXPERIMENTAL DETAILS AND SAMPLE PREPARATION

We grew monolayer islands of MoS<sub>2</sub> on a pristine Au(111) substrate, which had been cleaned by repeated cycles of sputtering and annealing. We first deposited Mo atoms on the surface and subsequently annealed the sample at 800 K in H<sub>2</sub>S gas at a pressure of  $p = 10^{-5}$  mbar. Inspection by scanning tunneling microscopy (STM) assured the successful formation of MoS<sub>2</sub> islands, which were characterized in more detail in earlier studies [31]. To introduce S vacancies in the top layer, we then irradiated the as-prepared sample with a beam of Ne ions with kinetic energy of 100 eV and an incidence angle of 55° with respect to the surface normal.

The same preparation conditions were used in two different UHV chambers, connected to different STM setups. The first enabled the simultaneous investigation by atomic force microscopy (AFM) using a qPlus tuning fork at a temperature 4.5 K. The second setup was used for temperature-dependent tunneling spectroscopy in a range spanning from 1 to 28 K.

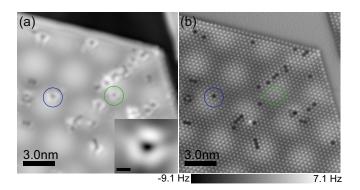


FIG. 1. Characterization of single top-layer sulfur vacancies in  $MoS_2$ . (a) STM topography of a  $MoS_2$  island after sputtering. Several defects appear with a dark center and a bright threefold rim (closeup view in inset). The constant-current STM image was recorded at a setpoint of 100 mV and 200 pA, the inset at 300 mV and 200 pA. The scale bar in the inset is 5 Å. (b) Constant-height  $\Delta f$  image, resolving the atomic structure of the terminating layer. Some S atoms are missing. These are at the location of the bright-rim defects in (a). The  $\Delta f$  image was recorded at a setpoint of 1 mV and 200 pA.

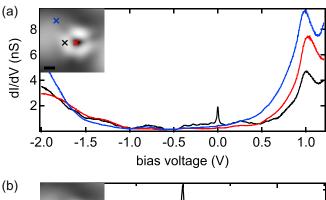
Additionally, the sample could be subject to a magnetic field up to 3 T.

#### III. IDENTIFICATION OF S VACANCIES IN MoS2 islands

We start by characterizing the structure of the MoS<sub>2</sub> islands after Ne bombardment. The STM images [Fig. 1(a)] reveal the typical hexagonal structure originating in the moiré superstructure forming as a consequence of the lattice mismatch between the terminating S layer and the Au(111) substrate. At the same time, the image also reveals randomly distributed features, consisting of a dark center and a bright rim. A closeup view on one of these defects is displayed in the inset of Fig. 1(a). The rim appears with a threefold symmetric shape. A similar shape has been reported from theoretical and experimental studies of chalcogen vacancies in (other) TMDCs [20,32–34]. It is thus tempting to assign these defects to missing S atoms. Yet, to obtain complementary insights into the origin of the defects, we probed the frequency-shift  $(\Delta f)$  signal of the very same area [Fig. 1(b)]. This image resolves the atomic structure of the top S layer and confirms that some S atoms are missing. Comparison of the STM and AFM image allows us to associate most of the dark features surrounded by a bright rim to S vacancies. One of these is highlighted with the blue circle in Figs. 1(a) and 1(b). When several S atoms are missing in neighboring sites, the rim shape is distorted. However, some few bright features in the STM image cannot be assigned to missing top-layer S atoms, as the top layer remains intact [green circles in Figs. 1(a) and 1(b)]. Hence, these must originate in interstitials or bottom-layer sulfur vacancies [32] that have been incorporated in the layer during its growth process.

# IV. ELECTRONIC AND MAGNETIC PROPERTIES OF SULFUR VACANCIES

Having successfully created top-layer S vacancies, we now turn to their electronic characterization. For comparison, we



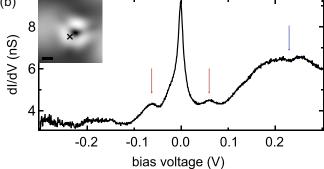


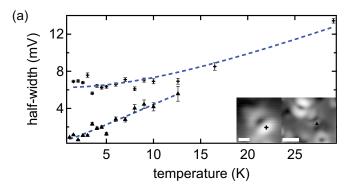
FIG. 2. Electronic structure of top-layer vacancies. (a) dI/dV spectra recorded on the locations indicated in the insets, revealing the semiconducting band gap of  $MoS_2$  and a zero-bias resonance on the defect's rim (feedback opened at -2 V and 200 pA,  $V_{mod} = 5$  mV). (b) dI/dV spectrum around the Fermi level recorded on the rim of the defect (feedback opened at 300 mV and 200 pA, with an additional tip approach by 100 pm,  $V_{mod} = 2$  mV). The STM topographies in the insets were recorded at 300 mV and 200 pA. The scale bars in the insets are 5 Å.

first present a dI/dV spectrum on the intact  $MoS_2$ . It shows the semiconducting band gap, flanked by the onset of the valence band at -1.6 V and the onset of the conduction band at 0.9 V [Fig. 2(a), blue] [31]. A dI/dV spectrum recorded in the center of the S vacancy (red) looks very similar to the bare  $MoS_2$  spectrum, yet with the onset and the peak of the conduction band being shifted by a few tens of millivolts. The most notable feature associated to the S vacancy is, however, found on the threefold symmetric rim (black). Here, we detect a peak at the Fermi level, which is better brought out in the closeup view in Fig. 2(b). Additionally, we observe two narrow resonances at  $\pm$  60 mV and a broad one at  $\approx$  230 mV.

To unravel the origin of the zero-bias peak, we investigated the evolution of dI/dV spectra of several S vacancies with increasing temperature. We fit all line shapes by a Frota function [for an example, see Fig. 3(b)] and extract their half-widths  $\Gamma$  after subtraction of the Fermi-Dirac temperature broadening [35,36]. The results are plotted in Fig. 3(a) for two distinct defects. Both peak broadenings can be reproduced by the phenomenological expression for the temperature dependence of a spin-1/2 Kondo resonance [38–40]:

$$\Gamma(T) = \sqrt{(\alpha k_B T)^2 + 2(k_B T_K)^2},\tag{1}$$

albeit with different Kondo temperatures of  $T_K = 51 \pm 2 \text{ K}$  and  $T_K = 4 \pm 3 \text{ K}$ , respectively. The temperature



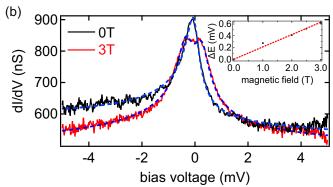


FIG. 3. Identification of the zero-bias peak as a Kondo resonance. (a) Extracted half-widths of two vacancies probed at different sample temperatures. To obtain the half-widths, we fitted the resonances with a Frota function and converted the Frota parameter to the half-width  $\Gamma$  [35,36]. The Fermi-Dirac temperature broadening of the tip was subtracted from the linewidths [37]. The temperaturedependent curve was fitted with the Fermi-liquid description of the Kondo problem [38,39]. The topographies of the defects are shown as insets, with the locations of the spectra marked by a cross and a triangle, according to the symbols in the plot. (b) dI/dV spectra recorded on the rim of the vacancy shown in the right inset in (a) and marked by a triangle at zero magnetic field (black) and in an applied magnetic field of 3 T. The blue dashed lines represent fits with one (0 T) or two separated (3 T) Frota functions, which are split by  $600 \pm 100 \, \mu V$ . Inset: linear fit of the Zeeman splitting of the Kondo resonance at different magnetic fields. The extracted g factor is given in the main text. The STM topographies in the insets in (a) were recorded at a setpoint of 50 mV and 3 nA (left) and 1 mV and 100 pA (right). The scale bars in the insets are 0.5 nm (left) and 1 nm (right). The dI/dV spectra were recorded after opening the feedback loop at 5 mV and 3 nA and with a modulation amplitude of  $V_{\text{mod}} = 50 \,\mu\text{V}$ .

dependencies thus indicate the presence of single-electron spins around the defect sites, which are exchange coupled to the substrate. We comment on the origin of the different Kondo temperatures below.

To further support the interpretation of the zero-bias peak as a Kondo resonance, we probe its behavior in an external magnetic field of 3 T perpendicular to the sample. Figure 3(b) shows such a dI/dV spectrum recorded on an S vacancy with a low Kondo temperature. The splitting of the resonance was extracted for measurements at several magnetic field strengths and yields a g factor of  $g = 1.8 \pm 0.1$  [Fig. 3(b), inset]. (Zero-bias peaks with significantly larger width, and thus larger Kondo temperatures, cannot be split in a magnetic

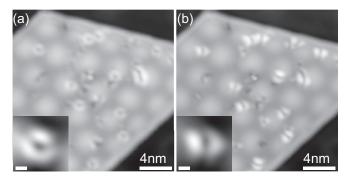


FIG. 4. Influence of the moiré structure on the defect appearance. (a) STM images recorded at 300 mV, 200 pA. (b) Same area and defect as in (a) recorded at 5 mV, 200 pA. Whereas the high bias voltage reveals a threefold shape, the images recorded close to the Kondo resonance show a broken symmetry imposed by the moiré modulated density of states.

field up to 3 T.) Following the assignment of the zero-bias peak as a Kondo resonance, the two narrow resonances at  $\pm$  60 mV in the dI/dV spectra [Fig. 2(b)] can tentatively be assigned to the excitation of the singly occupied resonance at negative bias voltage, separated by the Coulomb charging energy U=120 mV to the doubly occupied state at positive bias voltage [37,41].

As already mentioned above, we find different Kondo temperatures for different S vacancies. The extracted Kondo temperatures vary in a range from 4 to 220 K. We ascribe such large variation to the different sites of the defects with respect to the moiré structure of the  $MoS_2$  layer. A similar observation was made for Fe and Mn atoms and was explained by the modulated density of states at the Fermi level by the moiré structure [42,43]. Another indication of the moiré structure influencing the Kondo effect is found in the spatial distribution of the Kondo amplitude. While the electronic structure imaged at larger bias voltage revealed a threefold symmetric rim [Figs. 1(a) and 4(a)], the Kondo amplitude of most vacancies shows an almost twofold symmetric shape [Fig. 4(b), inset].

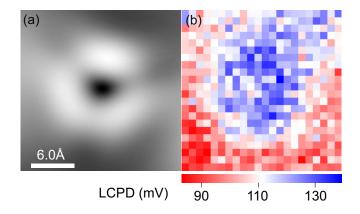


FIG. 5. Charge distribution around a sulfur vacancy. (a) Closeup STM topography of a sulfur vacancy (recorded at 300 mV and 200 pA). (b) LCPD extracted from a densely spaced grid of  $\Delta f - V$  spectra over the same area as in (a). The  $\Delta f - V$  spectra were recorded at a setpoint of 300 mV and 200 pA, with the tip being additionally approached towards the surface by 100 pm.

These distributions reflect the local symmetry of the moiré structure with the mirror axis aligning along the valleys of the moiré modulation. Hence, all our observations point to a strong impact of the electronic modulation of the density of states on the Kondo effect. However, we cannot exclude that some of the S defects may be occupied by rest-gas molecules from the UHV chamber, such as oxygen, which are hard to be distinguished from the bare S vacancies [44,45].

An unpaired electron spin must originate in a localized charge. To investigate the local charge distribution, we measure the local-contact-potential difference (LCPD) using a tuning-fork AFM. We extract the LCPD values from a grid of  $\Delta f - V$  spectra [Fig. 5(b)]. Comparing to the simultaneously recorded STM image, we associate the increase in LCPD to the S-vacancy site. A more positive LCPD value implies a negative charge localization, suggesting electron transfer from the metal to the defect site. This charge transfer is consistent with density-functional-theory calculations of S vacancies in MoS<sub>2</sub> on Au(111) [23]. Concomitant to the charge transfer, theory also predicts a Jahn-Teller distortion of the atomic structure [21,23]. However, the expected atomic displacements are very small (≈0.3 Å) and not unambiguously detectable in our AFM images. Yet, a distortion of the occupied electronic states around a S vacancy has recently been associated to the Jahn-Teller effect [46] and may also add to the distorted shape of the Kondo distribution.

## V. SULFUR VACANCIES IN PATCHES OF QUASI-FREE-STANDING MoS<sub>2</sub>

We have thus established that the Au substrate is of crucial importance for the formation of singly charged S vacancies, which are Kondo screened. To obtain direct insight into the role of the metal, it would be illuminating to investigate the same vacancies in the absence of the metal substrate. To do so, we take advantage of another type of defect of the MoS<sub>2</sub>/Au(111) sample. Some areas of the MoS<sub>2</sub> islands, typically several nanometers in diameter, appear slightly darker at large bias voltages and completely transparent at low bias voltage. These areal defects have been ascribed to the absence of a single atomic layer of Au atoms below the MoS<sub>2</sub> [47]. Figure 6(a) shows such an area (dark background) decorated by three S vacancies. Differential conductance spectra on such an area without S vacancies exhibit a band gap of similar width as expected for an isolated MoS<sub>2</sub> monolayer [48]. The conductance in the gap is almost zero, and the onsets of the valence and conduction band are much sharper than on Au [Fig. 6(b)]. Hence, hybridization with the metal is negligible, and we thus refer to these areas as quasi-freestanding MoS<sub>2</sub> monolayers [47]. Spectra taken on the S-vacancy sites show a resonance at-1.4 V in the occupied states and two unoccupied states at 450 mV and 650 mV within this band gap, whereas the region close to the Fermi level is essentially flat. A state

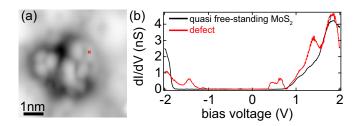


FIG. 6. Sulfur vacancies on quasi-freestanding  $MoS_2$ . (a) STM topography of point defects on a quasi-freestanding  $MoS_2$ . (b) dI/dV spectra recorded on a patch of quasi-freestanding  $MoS_2$  (black) and on a point defect, the latter marked by a red cross in the topography in (a). The topography was taken at a setpoint of 800 mV and 100 pA, the spectra were recorded at a setpoint of 2 V and 3 nA (red) and 800 mV and 100 pA (black).

close to the valence-band edge along with a spin-orbit split state in the unoccupied regime of the band gap have been predicted for freestanding  $MoS_2$  and to arise from dangling bonds with strong Mo-4d character [21,23,32,49]. Our observations are thus in agreement with a neutral vacancy state, which is stable in the absence of hybridization with a metal support, as also observed, e.g., in  $WS_2$  on silicon carbide [34].

#### VI. CONCLUSIONS

The characterization of defects in monolayers of TMDCs is of crucial importance for understanding the performance of electronic devices made of TMDC heterostructures. Here, we deliberately created S vacancies in monolayers of MoS<sub>2</sub> grown on a Au(111) surface by Ne-ion bombardment. We showed that these defects are singly charged, which we ascribe to charge transfer from the metal substrate. The localized electron is Kondo screened by the electron bath at the interface of MoS<sub>2</sub> to Au(111). Owing to a moiré-induced modulation of the density of states at the Fermi level, the exchange coupling to the substrate varies depending on the specific location of the S vacancy. Removal of a single Au layer in a small area below the MoS<sub>2</sub> immediately suppresses charge transfer. Our results highlight the impact of a metal substrate for controlling the charge state and magnetic properties of single-atom defects in MoS<sub>2</sub>.

The data that support the findings of this study are openly available in Zenodo at [50].

### ACKNOWLEDGMENTS

We thank Blanca Biel, Laëtitia Farinacci, Mariana Rossi, and Rika Simon for fruitful discussions. We acknowledge financial support by the Deutsche Forschungsgemeinschaft (DFG) through Project No. 328545488 (TRR 227, Project B05).

 Q. H. Wang, K. Kalantar-zadeh, A. Kis, J. Coleman, and M. Strano, Electronics and optoelectronics of two-dimensional transition metal dichalcogenides, Nat. Nanotechnol. 7, 699 (2012).

- [2] K. S. Novoselov, A. Mishchenko, A. Carvalho, and A. H. C. Neto, 2D materials and van der Waals heterostructures, Science 353, aac9439 (2016).
- [3] Z. Hu, Z. Wu, C. Han, J. He, Z. Ni, and W. Chen, Twodimensional transition metal dichalcogenides: Interface and defect engineering, Chem. Soc. Rev. 47, 3100 (2018).
- [4] Q. Liang, Q. Zhang, X. Zhao, M. Liu, and A. T. S. Wee, Defect engineering of two-dimensional transition-metal dichalcogenides: Applications, challenges, and opportunities, ACS Nano 15, 2165 (2021).
- [5] H. Qiu, T. Xu, Z. Wang, W. Ren, H. Nan, Z. Ni, Q. Chen, S. Yuan, F. Miao, F. Song, G. Long, Y. Shi, L. Sun, J. Wang, and X. Wang, Hopping transport through defect-induced localized states in molybdenum disulphide, Nat. Commun. 4, 2642 (2013).
- [6] Z. Yu, Y. Pan, Y. Shen, Z. Wang, Z.-Y. Ong, T. Xu, R. Xin, L. Pan, B. Wang, L. Sun, J. Wang, G. Zhang, Y. W. Zhang, Y. Shi, and X. Wang, Towards intrinsic charge transport in monolayer molybdenum disulfide by defect and interface engineering, Nat. Commun. 5, 5290 (2014).
- [7] S. KC, R. C. Longo, R. Addou, R. M. Wallace, and K. Cho, Impact of intrinsic atomic defects on the electronic structure of MoS<sub>2</sub> monolayers, Nanotechnology 25, 375703 (2014).
- [8] H. Nan, Z. Wang, W. Wang, Z. Liang, Y. Lu, Q. Chen, D. He, P. Tan, F. Miao, X. Wang, J. Wang, and Z. Ni, Strong photoluminescence enhancement of MoS<sub>2</sub> through defect engineering and oxygen bonding, ACS Nano 8, 5738 (2014).
- [9] P. K. Chow, R. B. Jacobs-Gedrim, J. Gao, T.-M. Lu, B. Yu, H. Terrones, and N. Koratkar, Defect-induced photoluminescence in monolayer semiconducting transition metal dichalcogenides, ACS Nano 9, 1520 (2015).
- [10] Y.-C. Lin, S. Li, H.-P. Komsa, L.-J. Chang, A. V. Krasheninnikov, G. Eda, and K. Suenaga, Revealing the atomic defects of WS<sub>2</sub> governing its distinct optical emissions, Adv. Funct. Mater. 28, 1704210 (2018).
- [11] S.-S. Chee, W.-J. Lee, Y.-R. Jo, M. K. Cho, D. Chun, H. Baik, B.-J. Kim, M.-H. Yoon, K. Lee, and M.-H. Ham, Atomic vacancy control and elemental substitution in a monolayer molybdenum disulfide for high performance optoelectronic device arrays, Adv. Funct. Mater. 30, 1908147 (2020).
- [12] J. Yang, F. Bussolotti, H. Kawai, and K. E. J. Goh, Tuning the conductivity type in monolayer WS<sub>2</sub> and MoS<sub>2</sub> by sulfur vacancies, Phys. Status Solidi RRL **14**, 2000248 (2020).
- [13] F. Bussolotti, J. Yang, H. Kawai, C. P. Y. Wong, and K. E. J. Goh, Impact of S-vacancies on the charge injection barrier at the electrical contact with the MoS<sub>2</sub> monolayer, ACS Nano 15, 2686 (2021).
- [14] E. Mitterreiter, B. Schuler, A. Micevic, D. Hernangomez-Perez, K. Barthelmi, K. A. Cochrane, J. Kiemle, F. Sigger, J. Klein, E. Wong, E. S. Barnard, K. Watanabe, T. Taniguchi, M. Lorke, F. Jahnke, J. J. Finley, A. M. Schwartzberg, D. Y. Qiu, S. Refaely-Abramson, A. W. Holleitner *et al.*, The role of chalcogen vacancies for atomic defect emission in MoS<sub>2</sub>, Nat. Commun. 12, 3822 (2021).
- [15] Y. Lin, E. Hathaway, F. Habis, Y. Wang, R. G. Rodriguez, K. Alnasser, N. Hurley, and J. Cui, Enhanced emission from defect levels in multilayer MoS<sub>2</sub>, Adv. Opt. Mater. 10, 2201059 (2022).
- [16] H. Li, C. Tsai, A. L. Koh, L. Cai, A. W. Contryman, A. H. Fragapane, J. Zhao, H. S. Han, H. C. Manoharan, F.

- Abild-Pedersen, J. K. Nørskov, and X. Zheng, Activating and optimizing MoS<sub>2</sub> basal planes for hydrogen evolution through the formation of strained sulphur vacancies, Nat. Mater. **15**, 48 (2016).
- [17] W. Zhou, X. Zou, S. Najmaei, Z. Liu, Y. Shi, J. Kong, J. Lou, P. M. Ajayan, B. I. Yakobson, and J.-C. Idrobo, Intrinsic structural defects in monolayer molybdenum disulfide, Nano Lett. 13, 2615 (2013).
- [18] H.-P. Komsa and A. V. Krasheninnikov, Native defects in bulk and monolayer MoS<sub>2</sub> from first principles, Phys. Rev. B 91, 125304 (2015).
- [19] Z. Lin, B. R. Carvalho, E. Kahn, R. Lv, R. Rao, H. Terrones, M. A. Pimenta, and M. Terrones, Defect engineering of twodimensional transition metal dichalcogenides, 2D Mater. 3, 022002 (2016).
- [20] F. Tumino, C. S. Casari, A. Li Bassi, and S. Tosoni, Nature of point defects in single-layer MoS<sub>2</sub> supported on Au(111), J. Phys. Chem. C 124, 12424 (2020).
- [21] A. M. Z. Tan, C. Freysoldt, and R. G. Hennig, Stability of charged sulfur vacancies in 2d and bulk MoS<sub>2</sub> from planewave density functional theory with electrostatic corrections, Phys. Rev. Mater. 4, 064004 (2020).
- [22] J. Yang, H. Kawai, C. P. Y. Wong, and K. E. J. Goh, Electrical doping effect of vacancies on monolayer MoS<sub>2</sub>, J. Phys. Chem. C 123, 2933 (2019).
- [23] A. Akkoush, Y. Litman, and M. Rossi, A hybrid-density functional theory study of intrinsic point defects in MX<sub>2</sub> (M=Mo,W; X=S,Se) monolayers, Phys. Status Solidi A, 2300180 (2023).
- [24] A. Li, J. Pan, Z. Yang, L. Zhou, X. Xiong, and F. Ouyang, Charge and strain induced magnetism in monolayer MoS<sub>2</sub> with S vacancy, J. Magn. Magn. Mater. 451, 520 (2018).
- [25] S. Tongay, S. S. Varnoosfaderani, B. R. Appleton, J. Wu, and A. F. Hebard, Magnetic properties of MoS<sub>2</sub>: Existence of ferromagnetism, Appl. Phys. Lett. 101, 123105 (2012).
- [26] W. Jolie, C. Murray, P. S. Weiß, J. Hall, F. Portner, N. Atodiresei, A. V. Krasheninnikov, C. Busse, H.-P. Komsa, A. Rosch, and T. Michely, Tomonaga-Luttinger liquid in a box: Electrons confined within MoS<sub>2</sub> mirror-twin boundaries, Phys. Rev. X 9, 011055 (2019).
- [27] C. van Efferen, J. Fischer, T. A. Costi, A. Rosch, T. Michely, and W. Jolie, Modulated Kondo screening along magnetic mirror twin boundaries in monolayer MoS2 on graphene, arXiv:2210.09675.
- [28] A. Splendiani, L. Sun, Y. Zhang, T. Li, J. Kim, C. Chim, G. Galli, and F. Wang, Emerging photoluminescence in monolayer MoS<sub>2</sub>, Nano Lett. 10, 1271 (2010).
- [29] K. F. Mak, C. Lee, J. Hone, J. Shan, and T. F. Heinz, Atomically thin MoS<sub>2</sub>: A new direct-gap semiconductor, Phys. Rev. Lett. **105**, 136805 (2010).
- [30] A. Bruix, J. A. Miwa, N. Hauptmann, D. Wegner, S. Ulstrup, S. S. Grønborg, C. E. Sanders, M. Dendzik, A. Grubišić Čabo, M. Bianchi, J. V. Lauritsen, A. A. Khajetoorians, B. Hammer, and P. Hofmann, Single-layer MoS<sub>2</sub> on Au(111): Band gap renormalization and substrate interaction, Phys. Rev. B 93, 165422 (2016).
- [31] N. Krane, C. Lotze, and K. J. Franke, Moiré structure of MoS<sub>2</sub> on Au(111): Local structural and electronic properties, Surf. Sci. 678, 136 (2018).

- [32] C. Gonzalez, B. Biel, and Y. J. Dappe, Theoretical characterisation of point defects on a MoS<sub>2</sub> monolayer by scanning tunnelling microscopy, Nanotechnology **27**, 105702 (2016).
- [33] P. Vancso, G. Z. Magda, J. Petö, J.-Y. Noh, Y.-S. Kim, C. Hwang, L. P. Biro, and L. Tapaszto, The intrinsic defect structure of exfoliated MoS<sub>2</sub> single layers revealed by scanning tunneling microscopy, Sci. Rep. 6, 29726 (2016).
- [34] B. Schuler, D. Y. Qiu, S. Refaely-Abramson, C. Kastl, C. T. Chen, S. Barja, R. J. Koch, D. F. Ogletree, S. Aloni, A. M. Schwartzberg, J. B. Neaton, S. G. Louie, and A. Weber-Bargioni, Large spin-orbit splitting of deep in-gap defect states of engineered sulfur vacancies in monolayer WS<sub>2</sub>, Phys. Rev. Lett. 123, 076801 (2019).
- [35] H. Prüser, M. Wenderoth, P. E. Dargel, A. Weismann, R. Peters, T. Pruschke, and R. G. Ulbrich, Long-range Kondo signature of a single magnetic impurity, Nat. Phys. 7, 203 (2011).
- [36] S. Frank and D. Jacob, Orbital signatures of Fano-Kondo line shapes in STM adatom spectroscopy, Phys. Rev. B 92, 235127 (2015).
- [37] D. Goldhaber-Gordon, J. Göres, M. A. Kastner, H. Shtrikman, D. Mahalu, and U. Meirav, From the Kondo regime to the mixed-valence regime in a single-electron transistor, Phys. Rev. Lett. 81, 5225 (1998).
- [38] P. Nozieres, A fermi-liquid description of the Kondo problem at low temperatures, J. Low Temp. Phys. 17, 31 (1974).
- [39] V. Madhavan, W. Chen, T. Jamneala, M. F. Crommie, and N. S. Wingreen, Tunneling into a single magnetic atom: Spectroscopic evidence of the Kondo resonance, Science 280, 567 (1998).
- [40] K. Nagaoka, T. Jamneala, M. Grobis, and M. F. Crommie, Temperature dependence of a single Kondo impurity, Phys. Rev. Lett. **88**, 077205 (2002).
- [41] I. Fernández-Torrente, K. J. Franke, and J. I. Pascual, Vibrational Kondo effect in pure organic charge-transfer assemblies, Phys. Rev. Lett. 101, 217203 (2008).

- [42] S. Trishin, C. Lotze, N. Bogdanoff, F. von Oppen, and K. J. Franke, Moiré tuning of spin excitations: Individual Fe atoms on MoS<sub>2</sub>/Au(111), Phys. Rev. Lett. **127**, 236801 (2021).
- [43] S. Trishin, C. Lotze, F. Lohss, G. Franceschi, L. I. Glazman, F. von Oppen, and K. J. Franke, Tuning a two-impurity Kondo system by a Moiré superstructure, Phys. Rev. Lett. 130, 176201 (2023).
- [44] S. Barja, S. Refaely-Abramson, B. Schuler, D. Y. Qiu, A. Pulkin, S. Wickenburg, H. Ryu, M. M. Ugeda, C. Kastl, C. Chen, C. Hwang, A. Schwartzberg, S. Aloni, S.-K. Mo, D. Frank Ogletree, M. F. Crommie, O. V. Yazyev, S. G. Louie, J. B. Neaton, and A. Weber-Bargioni, Identifying substitutional oxygen as a prolific point defect in monolayer transition metal dichalcogenides, Nat. Commun. 10, 3382 (2019).
- [45] K. A. Cochrane, J.-H. Lee, C. Kastl, J. B. Haber, T. Zhang, A. Kozhakhmetov, J. A. Robinson, M. Terrones, J. Repp, J. B. Neaton, A. Weber-Bargioni, and B. Schuler, Spin-dependent vibronic response of a carbon radical ion in two-dimensional WS<sub>2</sub>, Nat. Commun. 12, 7287 (2021).
- [46] F. Xiang, L. Huberich, P. A. Vargas, R. Torsi, J. Allerbeck, A. M. Z. Tan, C. Dong, P. Ruffieux, R. Fasel, O. Gröning, Y.-C. Lin, R. G. Hennig, J. A. Robinson, and B. Schuler, Charge statedependent symmetry breaking of atomic defects in transition metal dichalcogenides, arXiv:2308.02201.
- [47] N. Krane, C. Lotze, J. M. Läger, G. Reecht, and K. J. Franke, Electronic structure and luminescence of quasi-freestanding MoS<sub>2</sub> nanopatches on Au(111), Nano Lett. 16, 5163 (2016).
- [48] D. Y. Qiu, F. H. da Jornada, and S. G. Louie, Optical spectrum of MoS<sub>2</sub>: Many-body effects and diversity of exciton states, Phys. Rev. Lett. **111**, 216805 (2013).
- [49] V. Sorkin, H. Zhou, Z. G. Yu, K.-W. Ang, and Y.-W. Zhang, The effects of point defect type, location, and density on the Schottky barrier height of Au/MoS<sub>2</sub> heterojunction: A first-principles study, Sci. Rep. **12**, 18001 (2022).
- [50] 10.5281/zenodo.10001244.